

Title (en)

Method of fabricating an optical element, lithographic apparatus and device manufacturing method

Title (de)

Methode zur Erzeugung eines optischen Elements, lithographischer Apparat sowie Methode zur Herstellung eines Geräts

Title (fr)

Méthode pour réaliser un élément optique, appareil lithographique ainsi que méthode pour fabriquer un objet

Publication

**EP 1426821 B1 20171018 (EN)**

Application

**EP 03257400 A 20031124**

Priority

- EP 03257400 A 20031124
- EP 02258121 A 20021126

Abstract (en)

[origin: EP1426821A1] A fabrication technique for manufacturing an optical element is disclosed. It involves selectively plasma etching a multi-layer stack and covering the obtained relief profile with a film, for example a reflective coating. <IMAGE>

IPC 8 full level

**G03F 1/24** (2012.01); **G03F 7/00** (2006.01); **G21K 1/06** (2006.01)

CPC (source: EP)

**B82Y 10/00** (2013.01); **B82Y 40/00** (2013.01); **G03F 1/24** (2013.01); **G03F 7/001** (2013.01); **G21K 1/062** (2013.01); **G21K 2201/067** (2013.01)

Cited by

WO2012126954A1; US9442383B2; US9997268B2; TWI472800B; WO2024091829A1

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